

| Application/Control No. | Applicant(s)/Patent under Reexamination | |
|-------------------------|---|--|
| 10/001,495 | LI ET AL. | |
| Examiner | Art Unit | |
| Richard H. Kim | 2871 | |

| | SEARCHED | | |
|-------|----------|------|----------|
| Class | Subclass | Date | Examiner |
| | | | |
| | | | |
| | | | |
| | | | |
| | | | |
| | | | |
| | | | |
| | | | |
| | | | |
| _ | | | |
| | , | | |
| | , | | |
| | | | |
| | | | |
| | | | |

| INT | INTERFERENCE SEARCHED | | | |
|-------|-----------------------|------|----------|--|
| Class | Subclass | Date | Examiner | |
| | - | | | |
| | | | | |
| | | | | |
| | | | | |
| | | | | |
| | -,, | | | |

| SEARCH NOTES (INCLUDING SEARCH STRATEGY) | | | | |
|---|-----------|------|--|--|
| | DATE | EXMR | | |
| East Text Search (349/113; Jpo, epo, uspat, pgpub)-see printout | 9/15/2005 | RHK | | |
| | | | | |
| | | + | | |
| | | | | |
| r | | | | |
| | | | | |
| | | | | |
| | | · _ | | |